

**6.012 Microelectronic Devices and Circuits**  
Formula Sheet for Exam One, Fall 2009

Parameter Values:

$$\begin{aligned}
 q &= 1.6 \times 10^{-19} \text{ Coul} \\
 \epsilon_o &= 8.854 \times 10^{-14} \text{ F/cm} \\
 \epsilon_{r, Si} &= 11.7, \quad \epsilon_{Si} \approx 10^{-12} \text{ F/cm} \\
 n_i [Si @ RT] &\approx 10^{10} \text{ cm}^{-3} \\
 kT/q &\approx 0.025 \text{ V}; \quad (kT/q) \ln 10 \approx 0.06 \text{ V} \\
 1 \mu\text{m} &= 1 \times 10^{-4} \text{ cm}
 \end{aligned}$$

Periodic Table:

III	IV	V
B	C	N
Al	Si	P
Ga	Ge	As
In	Sn	Sb

Drift/Diffusion:

$$\begin{aligned}
 \text{Drift velocity: } \bar{s}_x &= \pm \mu_m E_x \\
 \text{Conductivity: } \sigma &= q(\mu_e n + \mu_h p) \\
 \text{Diffusion flux: } F_m &= -D_m \frac{\partial C_m}{\partial x} \\
 \text{Einstein relation: } \frac{D_m}{\mu_m} &= \frac{kT}{q}
 \end{aligned}$$

Electrostatics:

$$\begin{aligned}
 \epsilon \frac{dE(x)}{dx} &= \rho(x) & E(x) &= \frac{1}{\epsilon} \int \rho(x) dx \\
 -\frac{d\phi(x)}{dx} &= E(x) & \phi(x) &= -\int E(x) dx \\
 -\epsilon \frac{d^2\phi(x)}{dx^2} &= \rho(x) & \phi(x) &= -\frac{1}{\epsilon} \iint \rho(x) dx dx
 \end{aligned}$$

The Five Basic Equations:

$$\begin{aligned}
 \text{Electron continuity: } \frac{\partial n(x,t)}{\partial t} - \frac{1}{q} \frac{\partial J_e(x,t)}{\partial x} &= g_L(x,t) - [n(x,t) \cdot p(x,t) - n_i^2] r(T) \\
 \text{Hole continuity: } \frac{\partial p(x,t)}{\partial t} + \frac{1}{q} \frac{\partial J_h(x,t)}{\partial x} &= g_L(x,t) - [n(x,t) \cdot p(x,t) - n_i^2] r(T) \\
 \text{Electron current density: } J_e(x,t) &= q\mu_e n(x,t)E(x,t) + qD_e \frac{\partial n(x,t)}{\partial x} \\
 \text{Hole current density: } J_h(x,t) &= q\mu_h p(x,t)E(x,t) - qD_h \frac{\partial p(x,t)}{\partial x} \\
 \text{Poisson's equation: } \frac{\partial E(x,t)}{\partial x} &= \frac{q}{\epsilon} [p(x,t) - n(x,t) + N_d^+(x) - N_a^-(x)]
 \end{aligned}$$

Uniform doping, full ionization, TE

$$\begin{aligned}
 \text{n-type, } N_d \gg N_a \\
 n_o \approx N_d - N_a \equiv N_D, \quad p_o = n_i^2/n_o, \quad \phi_n &= \frac{kT}{q} \ln \frac{N_D}{n_i} \\
 \text{p-type, } N_a \gg N_d \\
 p_o \approx N_a - N_d \equiv N_A, \quad n_o = n_i^2/p_o, \quad \phi_p &= -\frac{kT}{q} \ln \frac{N_A}{n_i}
 \end{aligned}$$

Uniform optical excitation, uniform doping

$$\begin{aligned}
 n = n_o + n' \quad p = p_o + p' \quad n' = p' \quad \frac{dn'}{dt} &= g_l(t) - (p_o + n_o + n')n'r \\
 \text{Low level injection, } n', p' \ll p_o + n_o: \quad \frac{dn'}{dt} + \frac{n'}{\tau_{\min}} &= g_l(t) \quad \text{with } \tau_{\min} \approx (p_o r)^{-1}
 \end{aligned}$$

Flow problems (uniformly doped quasineutral regions with quasi-static excitation and low level injection; p-type example):

$$\text{Minority carrier excess: } \frac{d^2 n'(x)}{dx^2} - \frac{n'(x)}{L_e^2} = -\frac{1}{D_e} g_L(x) \quad L_e \equiv \sqrt{D_e \tau_e}$$

$$\text{Minority carrier current density: } J_e(x) \approx q D_e \frac{dn'(x)}{dx}$$

$$\text{Majority carrier current density: } J_h(x) = J_{Tot} - J_e(x)$$

$$\text{Electric field: } E_x(x) \approx \frac{1}{q \mu_h p_o} \left[ J_h(x) + \frac{D_h}{D_e} J_e(x) \right]$$

$$\text{Majority carrier excess: } p'(x) \approx n'(x) + \frac{\varepsilon}{q} \frac{dE_x(x)}{dx}$$

Short base, infinite lifetime limit:

$$\text{Minority carrier excess: } \frac{d^2 n'(x)}{dx^2} \approx -\frac{1}{D_e} g_L(x) \Rightarrow n'(x) \approx -\frac{1}{D_e} \iint g_L(x) dx dx$$

Non-uniformly doped semiconductor sample in thermal equilibrium

$$\frac{d^2 \phi(x)}{dx^2} = \frac{q}{\varepsilon} \left\{ n_i \left[ e^{q\phi(x)/kT} - e^{-q\phi(x)/kT} \right] - [N_d(x) - N_a(x)] \right\}$$

$$n_o(x) = n_i e^{q\phi(x)/kT}, \quad p_o(x) = n_i e^{-q\phi(x)/kT}, \quad p_o(x) n_o(x) = n_i^2$$

Depletion approximation for abrupt p-n junction:

$$\rho(x) = \begin{cases} 0 & \text{for } x < -x_p \\ -qN_{Ap} & \text{for } -x_p < x < 0 \\ qN_{Dn} & \text{for } 0 < x < x_n \\ 0 & \text{for } x_n < x \end{cases} \quad N_{Ap} x_p = N_{Dn} x_n$$

$$\phi_b \equiv \phi_n - \phi_p = \frac{kT}{q} \ln \frac{N_{Dn} N_{Ap}}{n_i^2}$$

$$w(v_{AB}) = \sqrt{\frac{2\varepsilon_{Si} (\phi_b - v_{AB}) (N_{Ap} + N_{Dn})}{q N_{Ap} N_{Dn}}} \quad |E_{pk}| = \sqrt{\frac{2q (\phi_b - v_{AB})}{\varepsilon_{Si}} \frac{N_{Ap} N_{Dn}}{(N_{Ap} + N_{Dn})}}$$

$$q_{DP}(v_{AB}) = -AqN_{Ap}x_p(v_{AB}) = -A \sqrt{2q\varepsilon_{Si} (\phi_b - v_{AB}) \frac{N_{Ap} N_{Dn}}{(N_{Ap} + N_{Dn})}}$$

Ideal p-n junction diode i-v relation:

$$n(-x_p) = \frac{n_i^2}{N_{Ap}} e^{qv_{AB}/kT}, \quad n'(-x_p) = \frac{n_i^2}{N_{Ap}} (e^{qv_{AB}/kT} - 1); \quad p(x_n) = \frac{n_i^2}{N_{Dn}} e^{qv_{AB}/kT}, \quad p'(x_n) = \frac{n_i^2}{N_{Dn}} (e^{qv_{AB}/kT} - 1)$$

$$i_D = Aq n_i^2 \left[ \frac{D_h}{N_{Dn} w_{n,eff}} + \frac{D_e}{N_{Ap} w_{p,eff}} \right] [e^{qv_{AB}/kT} - 1] \quad w_{m,eff} = \begin{cases} w_m - x_m & \text{if } L_m \gg w_m \\ L_m \tanh[(w_m - x_m)/L_m] & \text{if } L_m \sim w_m \\ L_m & \text{if } L_m \ll w_m \end{cases}$$

$$q_{QNR,p-side} = Aq \int_{-w_p}^{-x_p} n'(x) dx, \quad q_{QNR,n-side} = Aq \int_{x_n}^{w_n} p'(x) dx, \quad \text{Note: } p'(x) \approx n'(x) \text{ in QNRs}$$

Small Signal Linear Equivalent Circuit for a p-n Diode  
(n<sup>+</sup>-p doping assumed for C<sub>d</sub>)

$$g_d \equiv \left. \frac{\partial i_D}{\partial v_{AB}} \right|_Q = \frac{q}{kT} I_S e^{qV_{AB}/kT} \approx \frac{qI_D}{kT}, \quad C_d = C_{dp} + C_{df},$$

where  $C_{dp}(V_{AB}) = A \sqrt{\frac{q\epsilon_{Si}N_{Ap}}{2(\phi_b - V_{AB})}}$ , and  $C_{df}(V_{AB}) = \frac{qI_D}{kT} \frac{[w_p - x_p]^2}{2D_e} = g_d \tau_d$  with  $\tau_d \equiv \frac{[w_p - x_p]^2}{2D_e}$

Large signal BJT Model in Forward Active Region (FAR):  
(nnp with base width modulation)

$$i_B(v_{BE}, v_{CE}) = I_{BS} (e^{qv_{BE}/kT} - 1)$$

$$i_C(v_{BE}, v_{BC}) = \beta_F i_B(v_{BE}, v_{CE}) [1 + \lambda v_{CE}] = \beta_F I_{BS} (e^{qv_{BE}/kT} - 1) [1 + \lambda v_{CE}]$$

with:  $I_{BS} \equiv \frac{I_{ES}}{(\beta_F + 1)} = \frac{Aqn_i^2}{(\beta_F + 1)} \left( \frac{D_h}{N_{DE}w_{E,eff}} + \frac{D_e}{N_{AB}w_{B,eff}} \right)$ ,  $\beta_F \equiv \frac{\alpha_F}{(1 - \alpha_F)}$ , and  $\lambda \equiv \frac{1}{V_A}$

Also,  $\alpha_F = \frac{(1 - \delta_B)}{(1 + \delta_E)}$  and  $\beta_F \approx \frac{(1 - \delta_B)}{(\delta_E + \delta_B)}$  with  $\delta_E = \frac{D_h}{D_e} \cdot \frac{N_{AB}}{N_{DE}} \cdot \frac{w_{B,eff}}{w_{E,eff}}$  and  $\delta_B = \frac{w_{B,eff}^2}{2L_{eB}^2}$

When  $\delta_B \approx 0$  then  $\alpha_F \approx \frac{1}{(1 + \delta_E)}$  and  $\beta_F \approx \frac{1}{\delta_E}$

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